Assignment 6

1)	Distance between final lens and sample surface in SEM is called WORKING DISTANCE
2)	Smaller convergence angle of the electron beam in SEM leads to Depth of Focus
	○ smaller
	• greater
	ono change in
3)	Which type of secondary electrons are produced by the back scattered electrons exiting the sample
	○ SEI
	● SE II
	● SE III
4)	The electrons emitted after the beam interacts with the sample, having energy less than 50 eV is conventionally called as _
	Auger electrons
	Back scattered electrons
	transmitted electrons
	Secondary electrons
5)	As the Working distance in SEM decreases
	oresolution is better
	Depth of Focus decreases
	Magnification increases
	All of the above

High depth of field
High magnification
High depth of focus
7) The qualitative and quantitative elemental analysis is done by collecting
back scattered electrons
 X-rays form the surface of few nanometers thick
 secondary electrons
X-rays from depth of few microns
8) Misorientation across grain boundaries can be analysed by
EBSD-orientation mapping
EDS-elemental mapping
EBSD-kikuchi patterns
BSE imaging
9) What is the advantage of WDS than EDS?
easy operation
has multiple detectors
an even detect trace elements
can use high magnification
10) What source of diffractor is used in WDS and why?
polymers to capture all wavelength of X-rays from organic and inorganic specimens
Organic crystals to enable high wavelength X-rays from elements with lower atomic number
silicon crystals to enable high and low wavelength X-rays
Quartz crystals to enable low wavelength X-rays from elements with higher atomic number

6) Three dimentional kind of imaging is possible in SEM due to its

SE and BSE electrons